

L Number	Hits	Search Text	DB	Time stamp
2	1577	methyilsilane or methyl-silane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:07
3	149166	"ch.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:12
4	1138	"sih.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:13
5	426	"ch.sub.3" with "sih.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:13
6	310	"ch.sub.3" near3 "sih.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:07
7	1731	(methyilsilane or methyl-silane) or ("ch.sub.3" near3 "sih.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:13
8	0	annealing with ("ch.sub.3" near3 "sih.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:14
9	3	annealing with (methyilsilane or methyl-silane)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:16
11	4	(metal or conductive) with ("ch.sub.3" near3 "sih.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:13
10	32	(metal or conductive) with (methyilsilane or methyl-silane)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:25
12	6	((("20020187633") or ("5956594") or ("6383951")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:55
13	0	("capacitorand6").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 13:55
14	18	capacitor and ("ch.sub.3" near3 "sih.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:10

15	633	(plasma adj treatment) with ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:13
16	0	("ch.sub.3" near3 "sih.sub.3") and ((plasma adj treatment) with ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:11
17	2	(methyilsilane or methyl-silane) and ((plasma adj treatment) with ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:11
18	71	(metal or conductive) same ((plasma adj treatment) with ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:12
19	2400	plasma near4 ultraviolet	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:56
20	1459	(metal or conductive) and (plasma near4 ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:14
21	158832	(metal or conductive)and capacitor	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:14
22	273	(plasma near4 ultraviolet) and capacitor	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:15
23	77	(radio adj frequency or rf) and ((plasma adj treatment) with ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:16
24	8	(radio adj frequency or rf) same ((plasma adj treatment) with ultraviolet)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:41
25	346	(radio adj frequency or rf) same ultraviolet same power	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:55
26	212	plasma and ((radio adj frequency or rf) same ultraviolet same power)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:42
27	147	plasma same ((radio adj frequency or rf) same ultraviolet same power)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:42
29	70	(radio adj frequency or rf) same (methyilsilane or methyl-silane)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:55

28	23	(radio adj frequency or rf) same ("ch.sub.3" near3 "sih.sub.3")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:55
31	1	("ch.sub.3" near3 "sih.sub.3") same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 14:56
30	44	(methylsilane or methyl-silane) same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:04
32	35	inductively with plasma with ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:06
33	0	(methylsilane or methyl?silane) same aluminum same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:08
34	310	"ch.sub.3" near3 "sih.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:07
35	0	((("ch.sub.3" near3 "sih.sub.3")) same aluminum same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:08
36	0	("ch.sub.3" near3 "sih.sub.3") same aluminum same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:08
37	0	("ch.sub.3" near3 "sih.sub.3") same electrode same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:08
38	0	(methylsilane or methyl?silane) same electrode same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:08
39	2	(methylsilane or methyl?silane) same metal same ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/02/05 16:09